

Form PTO 1449

U.S. Department of Commerce
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Atty. Docket No.
Mo-6019 / LeA 33,933

Serial No.
09/829,684

Applicant
Steffen Hofacker et al

Filing Date
April 10, 2001

Group
1773

U.S. PATENT DOCUMENTS

| EXAMINER INITIALS | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
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FOREIGN PATENT DOCUMENTS

| | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION Yes No* |
|----|-----------------|----------|---------|-------|----------|------------------------|
| AL | 0 763 581 | 03/19/97 | Europe | | | |
| AM | 00/27931 | 05/18/00 | World | | | |
| AN | 00/55656 | 09/21/00 | World | | | |
| AO | | | | | | |
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OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

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| AR | Database Caplus 'Online! Chemical Abstracts Service, Columbus, Ohio, US; Li Haoying: "Preparation of organic-inorganic multifunctional nanocomposite coating via sol-gel routes." Database accession no. 2001:803211 XP002217690 Zusammenfassung & Journal Of Nanoparticle Research Bd. 3, Nr. 2-3, 2001, Seiten 157-160. |
| AS | Patent Abstracts of Japan Vol. 1996, No. 10, 31. Oktober 1996 (1996-10-31) & JP 08 165145 A (Tonen Corp), 25. Juni 1996 (1996-06-25) Zusammenfassung & Database Caplus 'Online! Chemical Abstracts Service, Columbus, Ohio, US; 1996:583526, 1996 Zusammenfassung. |
| AT | Patent Abstracts of Japan Vol. 1995, No. 07, 31. August 1995 (1995-08-31) & JP 07 097535 A (Sumitomo Osaka Cement Co Ltd; Others: 01); 11. April 1995 (1995-04-11) Zusammenfassung. |
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| EXAMINER Initial if references considered, whether or not citation is in conformance with MPEP 609; Draw line through if not in conformance and not considered. Include copy of this form with next communication to applicant. | |

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| 84 | AR | Patent Abstracts of Japan Vol. 1995, No. 07, 31. August 1995 (1995-08-31) & JP 2000 007996 A (Hitachi Ltd), 11. Januar 2000 (2000-01-11) Zusammenfassung. |
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| EXAMINER <i>Shuba Shm</i> | | DATE CONSIDERED <i>6/23/02</i> |
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